



Micronic Receives Order for Advanced TFT-LCD Photomask Pattern Generator

Taby, Sweden – October 21, 2004 – Micronic Laser Systems has received an order for an LRS Series laser pattern generator from an Asian customer. The LRS Series tool will be used in the production of advanced TFT-LCD photomasks.

“This order demonstrates that display manufacturers worldwide are continuing to add capacity for photomask production,” said Sven Lofquist, Micronic president and CEO. “With our production-proven line of display photomask pattern generators and our long history in this market, Micronic remains well poised to continue to benefit from the expanding TFT market.”

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About Micronic Laser Systems AB

Micronic Laser Systems AB is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's product offering also includes metrology systems for display photomasks. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Taby, north of Stockholm and at present has subsidiaries in the United States, Japan and Taiwan. Micronic maintains a web site at: <http://www.micronic.se>